

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	21	(ceramic near (heat\$4 pedestal holder) with protect\$4 near4 (coat\$4 film layer)).clm.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/10 13:40
L2	7	(ceramic near (heat\$4 pedestal holder) with protect\$4 near4 (coat\$4 film layer)).clm. and vapor near deposit\$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/10 13:42
S1	2	"20020072211".pn.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 09:29
S2	0	ruthenium with silicon same season\$3 and (CVD vapor near deposit \$4)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 09:53
S3	0	ruthenium same4 silicon same season\$3 and (CVD vapor near deposit \$4)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 09:54
S4	0	ruthenium same silicon same season\$3 and (CVD vapor near deposit \$4)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 09:54
S5	6	ruthenium same silicon and season\$3 and (CVD vapor near deposit\$4)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 09:54

S6	20	(reseason\$4)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 09:54
S7	26969	(condition\$4 season\$4 pretreat\$4) with ("sio. sub.2" silica silicon si) and (CVD vapor near deposit\$4)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 09:56
S8	1719	(condition\$4 season\$4 pretreat\$4) with chamber with ("sio. sub.2" silica silicon si) and (CVD vapor near deposit\$4)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 09:57
S9	67	(condition\$4 season\$4 pretreat\$4) with chamber with ("sio. sub.2" silica silicon si) and (CVD vapor near deposit\$4) and ruthenium	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 09:57
S10	2	"6413321".pn.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:04
S11	2	"6452775".pn.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:06
S12	210	(plurality multiple more near one) with season\$3 with (chamber film layer)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:15
S13	256	(plurality multiple more near one repeat\$4) with season\$3 with (chamber film layer)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:15

S14	115	(plurality multiple more near one) with season\$3 with (chamber)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:16
S15	50	(plurality multiple more near one) with season\$3 with (chamber) and vapor near deposit\$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:16
S16	8	backside near contaminat\$4 and season\$4 with ("sio.sub.2" silica silicon si)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:21
S17	17	("3627590" "4798165" "5045346" "5221414" "5230741" "5238499" "5244730" "5350427" "5366585" "5374594" "5447570" "5589233" "5614055" "5855681" "5871811" "5879128" "6020035").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2008/06/03 10:22
S18	8	backside near contaminat\$4 and season\$4 same ("sio.sub.2" silica silicon si)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:27
S19	8	backside near contaminat\$4 and season\$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:28
S20	507	backside near contaminat\$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:28
S21	102	backside near contaminat\$4 and barrier near layer	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:28

S22	0	backside near contaminat \$4 and barrier near layer and ceramic near heater	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:28
S23	42	backside near contaminat \$4 and barrier near layer and ceramic	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:28
S25	42	backside near contaminat \$4 and barrier near layer and ceramic and metal	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:28
S26	9	backside near contaminat \$4 and (season\$4 condition\$4) with (multiple repetitive repeat redo)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:41
S27	1	427/250,237,230.ccls. and pedestal and pretreat \$4 same metal	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:42
S28	2	"20040071878".pn.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:49
S29	0	chamber near season\$4 same silicon near (oxide dioxide) and ruthenium	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:51
S30	1	season\$4 same silicon near (oxide dioxide) and ruthenium	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 10:51

S31	74	ru/si	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 11:03
S32	0	(ru/si rusi\$5) with barrier near layer same season \$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 11:03
S33	70	ceramic near heater same (protect\$4 barrier) and contamination	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 11:06
S34	2	ceramic near heater and (protect\$4 barrier) same contamination near3 (back adj side backside)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 11:24
S35	20	ceramic near heater and (protect\$4 barrier) and contamination near3 (back adj side backside)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 11:25
S36	2	ceramic near heater same (protect\$4 barrier season\$4) and contamination near3 (back adj side backside)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 11:26
S37	33	(multilayer) with season \$3 with (chamber film layer)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 11:34
S38	7114	(multilayer) with protect \$4 with (chamber film layer)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 11:49

S39	436	(multilayer) with protect \$4 with (chamber film layer) and (ruthenium)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 11:50
S40	52	(multilayer) with protect \$4 with (chamber film layer) and (ruthenium) with silicon	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 11:50
S41	2	10/810912	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 11:53
S42	10591	cover\$4 same metal with (deposit\$4 contaminant \$4) same ("sio.sub.2" silica silicon si)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 11:55
S43	3587	cover\$4 with metal with (deposit\$4 contaminant \$4) same ("sio.sub.2" silica silicon si)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 11:55
S44	1558	cover\$4 with metal with (deposit\$4 contaminant \$4) same ("sio.sub.2" silica silicon near2 (oxide dioxide))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 11:55
S45	58	cover\$4 with metal with (deposit\$4 contaminant \$4) same ("sio.sub.2" silica silicon near2 (oxide dioxide)) same chamber	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 11:55
S46	626	ceramic near heat\$4 with protect\$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 12:56

S47	288	ceramic near heat\$4 with protect\$4 near4 (coat\$4 film layer)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 12:56
S48	28	ceramic near heat\$4 with protect\$4 near4 (coat\$4 film layer) and contaminat\$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 12:57
S49	12	ceramic near (heat\$4 pedestal holder) with protect\$4 near4 (coat\$4 film layer) and contaminat\$4 and vapor near deposit\$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/03 13:32

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